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PATENT
1155-0246P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: Hidetatsu MURAKAMI et al. Conf.: 2681
Appl. No.: 10/088,917 Group: 1713
Filed: March 25, 2002 Examiner: Lee
For: NOVEL ETHYLENE COPOLYMER AND USES
THEREOF

LETTER SUBMITTING DOCUMENTS AFTER PAYMENT OF ISSUE FEE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

OCT 12 2004

Sir:

Applicant submits the following references that were cited in a corresponding European Search Report (copy enclosed) but were not available to applicant's representative until after payment of the issue fee. A copy of the references together with a listing on Form PTO-1449, is submitted herewith. Applicant requests that this information be placed in the application file.

Respectfully submitted,

BIRCH, STEWART, KOLASCH & BIRCH, LLP

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MSW
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1155-0246P
Attachment(s)

Form PTO-1449

ATTY. DOCKET NO.
1155-0246PAPPLICATION NO.
10/088,917**INFORMATION DISCLOSURE CITATION
IN AN APPLICATION**

(Use several sheets if necessary)

APPLICANT
Hidetatsu MURAKAMI et al.FILING DATE
March 25, 2002GROUP
1713**U.S. PATENT DOCUMENTS**

DOCUMENT NUMBER	Kind	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
US						
US						
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FOREIGN PATENT DOCUMENTS

Office	DOCUMENT NUMBER	Kind	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION	
							YES	NO
EP	0 667 359	A1	1995-08-16	EUROPE			X	

OTHER DOCUMENTS

(Include Name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.) date, page(s), volume-issue number(s), publisher, city and/or country where published.

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.